Notice of References Cited

Application/Control No. 09/674,994	Reexamination	Applicant(s)/Patent Under Reexamination ALPEROVICH ET AL.		
Examiner	Art Unit			
Martin J Angebranndt	1756	Page 1 of 1		

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	А	US-6277460	08-2001	Min et al.	430/945
	В	US-6009065	12-1999	Glushko et al.	369/112
	С	US-4412231	10-1983	Namba et al.	430/945
	D	US-4090031	05-1978	Russell	358/130
	E	US-5470994	11-1995	Saeva et al.	556/64
	F	US-			
	G	US-			
	Н	US-			
	ı	US-			
	J	US-			
	к	US-			
	L	US-			
	М	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	09-011619	01-1997	Japan	***	
	0	54-061541	05-1979	Japan	****	
	Р	59-092448	05-1984	Japan	Sasoka	
	Q	62-239436	10-1987	Japan	Santo	
	R	02-076126	03-1990	Japan	Hashida et al.	
	s					
	Т					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
	Crivello et al., "Triaryl Sulfonium Salts as Photoinitiators of Free Radical and Cationic Polymerization", J. Polymer Sci." Lette Vol 17, pp. 759-764, (1979)				
	٧				
	w				
	х				

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.